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Cover figure: Energy band dispersion of CeNiAl with a fatband contribution for Ce-4f. $\Gamma = (0, 0, 0)$, $K = (0, 1/2, 0)$, $M = (1/2, 1/2, 0)$, $A = (0, 0, 1/2)$, $L = (1/2, 1/2, 1/2)$ and $H = (0, 1/2, 1/2)$. Below, an electron density map at Γ -point for the most stable band with Ce-4f character is shown.